

SHIGA7.029APC

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Hojo et al.
Appl. No.	:	Unknown
Filed	:	Herewith
For	:	POSITIVE RESIST COMPOSITION AND METHOD OF FORMATION OF RESIST PATTERNS
Examiner	:	Unknown
Group Art Unit	:	Unknown

**PRELIMINARY AMENDMENT**

**Mail Stop Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

Prior to examination, please amend the above referenced 371 U.S. national phase application filed herewith as follows:

**Amendments to the Specification** begin on page 2 of this paper.

**Remarks/Arguments** begin on page 3 of this paper.